

ALTERNATIVE TO PTO/SB/08A/B (04/07)

INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Complete if Known		
				Application Number 10/727,696		
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				First Named Inventor	Chaitan KHOSLA	
				Art Unit	1656	
(Use as many sheets as necessary)			necessary)	Examiner Name	N.T. Nachad Alexander Kim	
Sheet	1	of	1	Attorney Docket Number	300622000508	

			U.S. PA	TENT DOCUMENTS	
Examiner Initials*	Cite No.1	Document Number	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			
	1.	US-5,098,837	03-24-1992	Beckmann et al.	
	2.	US-5,149,639	09-22-1992	Katz et al.	
	3.	US-5,252,474	10/1993	Gewain et al.	
	4.	US-6,060,234	05/2000	Katz et al.	

FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ -Number ⁴ -Kind Code ⁵ (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Τ°	

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NON PATENT LITERATURE DOCUMENTS							
Examiner Initials	Cite No.1	The manazina journal carial symposium catalog etc.) date hade(s) volume-issue humber(s) hublisher cuv					
	5.	BEDFORD et al., Chemistry and Biology (1996) 3:827-831					
	6.	BROWN et al., J. Chem. Soc. Chem. Commun. (1995) 15:1517-1518					
	7.	DONADIO et al., Gene (1992) 115:97-103					
	8.	DONADIO et al., Industrial Microorganism, Basic and Applied Molecular Genetics, R. H. Baltz, G. D. Hegeman and PIL. Skatrud (eds.), Amer. Soc. Microbial., Washington D.C., 1993, pages 257–265.					
	9.	DONADIO et al., Proc. Natl. Acad. Sci. USA (1993) 90:7119-7123					
	10.	DONADIO et al., Science (1991) 252:675-679					
	11.	HUTCHINSON, Bio/Technology (1994) 12:375-380					
	12.	KHOSLA et al., Tibtech (1996) 14:335-341					
	13.	LIU et al., JACS (1997) 119:10553-10554					
	14.	MACNEIL et al., Gene (1992) 115:119-125					
	15.	MACNEIL et al., Industrial Microorganisms: Basic and Applied Molecular Genetics (1993) 30:245-256					
	16.	MARSDEN et al., Science (1998) 279:199-202					
	17.	MCALPINE et al., The Journal of Antibiotics (1987) 40(8):1115-1122					
	18.	ROHR, Chem. Int. Ed. Engl. (1995) 34(8):881-886					
	19.	RUAN et al., J. of Bacteriology (1997) 79(20):6416-6425					
	20.	STASSI et al., PNAS (1998) 95:7305-7309					

Examiner	/Alayandar Kim/	Date	06/23/2008
Signature	/Alexander Kim/	Considered	00/20/2000